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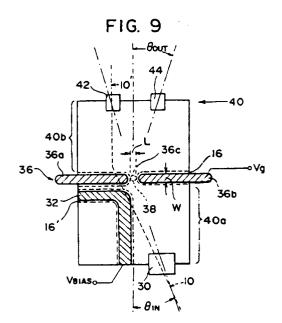
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©4) Ouantum semiconductor device that uses a quantum point contact for producing a quantum mechanical carrier wave with directivity.

57) A quantum semiconductor device comprises a channel region (40) formed with a two-dimensional carrier gas, a Schottky electrode structure (36) provided on the channel region for creating a depletion region (16) in the channel region to extend in a lateral direction such that the two-dimensional carrier gas is divided into a first region and a second region, a quantum point contact (38) formed in the depletion region to connect the first and second regions of the two-dimensional carrier gas in a longitudinal direction, an emitter electrode (30) provided on the channel region in correspondence to the first region of the two-dimensional carrier gas, one or more collector electrodes (42, 44) provided on the channel region in correspondence to the second region of the two-dimensional carrier gas, and another Schottky electrode structure (32, 34) provided in correspondence to the first region for creating a depletion region therein such that a path of the carriers entering into the quantum point contact is controlled asymmetrical with respect to a hypothetical longitudinal axis that passes through the quantum point contact in the longitudinal direction.





**DOCUMENTS CONSIDERED TO BE RELEVANT** 

European Patent
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EP 92 71 0014

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Category	Citation of document with ind of relevant pass	lication, where app sages	ropriate,	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
A	PATENT ABSTRACTS OF vol. 14, no. 170 (E- & JP-A-20 27 739 ( N * abstract *	913)30 Marc	h 1990 uary 1990	1-14	H01L29/76 H01L29/14
					TECHNICAL FIELDS SEARCHED (Int. Cl.5)
					H01L
	The present search report has been	en drawn up for all	claims		
Place of search THE HAGUE		Date of coa 26 MAY	npletion of the search 1993		Examiner VENDANGE P.
CATEGORY OF CITED DOCUMENTS  X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background			T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons		
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